

1 **SUPPORTING INFORMATION**

2 **Dezincification of Brass Water Meters in a Long-term Study: Effects of Anions,**
3 **Alkalinity, and Residual Chlorine in Tap Water**

4 Shu-Ju Chao^a, Ming-Han Tsai^a, Rui-Pei Yu^a, Lap-Cuong Hua^a, Chi-Chang. Hu^b, Chihpin Huang^{a,*}

5 ^a: Institute of Environmental Engineering, National Yang Ming Chiao Tung University, Hsinchu 300, Taiwan.

6 ^b: Department of Chemical Engineering, National Tsing Hua University, Hsinchu 300, Taiwan

7 *: correspondence author: Chihpin Huang, huang@nctu.edu.tw

8

9

10

Table S1 Characteristics of Hsinchu tap water

Water quality	Value
pH	7.93±0.19
Free chlorine (mg/L)	0.16±0.15
Conductivity (µS/cm)	300±29
Turbidity (NTU)	0.23±1.0
Hardness (mg/L)	122±17
Alkalinity (mg/L)	120±19
Sulphate (mg/L)	46.9±9
Chloride (mg/L)	11.3±4.1

11

12 **Text S1**

13 **Table S2** shows the change of water qualities for various synthetic waters. In the high Alk
14 groups ($A_{High}B_{High}C_{Low}$ and $A_{High}B_{High}C_{High}$), average Alk slightly decreased from 230 to 191 mg/L
15 after 7-day exposure of tested water and water meter. By contrast, an insignificant change (< 10%)
16 was observed in the low Alk groups as well as the control group. For low RC groups
17 ($A_{High}B_{High}C_{Low}$ and $A_{High}B_{Low}C_{Low}$), DO decreased from 8.64±0.2 to 7.06±0.6 mg/L, while it
18 decreased from 8.91±0.2 to 7.94±0.1 mg/L in the high RC groups ($A_{High}B_{High}C_{High}$ and
19 $A_{High}B_{Low}C_{High}$). On the contrary, low RC slightly reduced the ORP (ΔORP : 150±84 mV) which
20 is much lower than that in the high RC condition (ΔORP : 409.0±4.9 mV). An overall increase in

21 pH from around 8.09 to around 8.25 was found in all tested groups after 7-day exposure. This was
22 likely attributed to the oxygen reduction reaction (ORR, $O_2 + 2H_2O + 4e^- \rightarrow 4OH^-$). The pH ~8.2
23 on the 7th day occurred in all tested groups might indicate a favorable pH condition for
24 dezincification, as reported by Mahdy *et al.* (2013).

Table S2 Change of water qualities for various synthetic waters

	Day	Alkalinity (mg/L as CaCO ₃)	DO (mg/L)	ORP (mV)	pH	Conductivity (μS/cm)	Chlorine (mg/L as Cl ₂)	Sulfate (mg/L)	Chloride (mg/L)
A_{Low}B_{Low}C_{Low}	1 st	129±23	8.85±1.0	466±181	8.09±0.1	316±114	0.49±0.6	62±7	6.42±1.2
	7 th	120±10	7.46±1.0	262±3	8.20±0.2	286±5	0.04±0.1	64±12	6.25±0.4
A_{High}B_{High}C_{Low}	1 st	229±28	8.36±1.6	343±122	8.07±0.1	639±84	0.31±0.2	115±11	66.93±2.6
	7 th	188±27	6.42±1.8	253±11	8.26±0.2	623±56	0.05±0.1	84±57	59.95±6.2
A_{High}B_{High}C_{High}	1 st	230±21	9.09±0.4	638±55	8.08±0.2	631±140	1.01±1.1	116±1.2	59.25±3.1
	7 th	194±28	8.01±0.8	232±17	8.25±0.3	637±44	0.29±0.2	127±7.4	61.99±2.2
A_{High}B_{Low}C_{Low}	1 st	120±12	8.71±1.1	443±103	8.09±0.1	530±23	0.24±0.1	115±14	52.29±3.5
	7 th	114±9.4	7.29±1.1	233±17	8.18±0.2	526±23	0.04±0.1	126±10	56.99±9.0
A_{High}B_{Low}C_{High}	1 st	120±0.0	8.74±1.2	640±41	8.11±0.1	558±68	1.00±1.3	125±7.3	59.52±2.8
	7 th	120±7.1	7.87±1.2	227±16	8.21±0.2	536±44	0.18±0.1	122±9.2	55.58±4.8

Errors indicate the replicate of over 90 measurements

High concentration: _{High}, Low concentration: _{Low}

Anions: A; Alkalinity (bicarbonate): B, Residual chlorine: C

Dissolved oxygen: DO, oxidation reduction potential: ORP

Table S3 Leaching rate of Zn and Cu of brass water meters under various mixed parameters water quality

Mixed water parameters	Day 0-30 (mg/L day)		Day 31-240 (mg/L day)		Day 240-360 (mg/L day)	
	Zn	Cu	Zn	Cu	Zn	Cu
A_{Low}B_{Low}C_{Low}	0.550 (0.97)	0.073 (0.96)	0.310 (0.96)	0.027 (0.95)	0.330 (0.68)	0.004 (0.94)
A_{High}B_{High}C_{Low}	0.590 (0.93)	0.010 (0.90)	0.380 (0.95)	0.007 (0.81)	0.360 (0.72)	0.003 (0.97)
A_{High}B_{High}C_{High}	0.590 (0.93)	0.070 (0.94)	0.420 (0.98)	0.011 (0.89)	0.360 (0.70)	0.004 (0.96)
A_{High}B_{Low}C_{Low}	0.720 (0.92)	0.010 (0.90)	0.540 (0.99)	0.003 (0.87)	0.390 (0.66)	0.003 (0.97)
A_{High}B_{Low}C_{High}	0.720 (0.92)	0.010 (0.90)	0.590 (0.99)	0.005 (0.97)	0.390 (0.70)	0.003 (0.98)

Anions: A; Alkalinity (bicarbonate): B; Residual chlorine: C.

High concentration: _{High}; Low concentration: _{Low}.

Δ Concentration of Zinc or Copper

Leaching rate = $\frac{\Delta \text{Concentration of Zinc or Copper}}{\Delta \text{Day}}$

The number in the blanket indicates the R² value

Table S4 Quantified chemical composition of the scale formed by ICP-OES

Testing groups	Al	K	Ca	Mn	Fe	Ni	Cu	Zn	Pb	Mg
	mg/g scale									
A_{Low}B_{Low}C_{Low}	32.6	0.00	2.20	0.22	1.60	2.32	6.12	437	1.13	0.36
A_{High}B_{High}C_{Low}	21.5	0.29	4.55	0.11	2.76	0.50	4.98	428	1.12	0.39
A_{High}B_{High}C_{High}	12.6	0.00	3.60	0.30	2.67	2.71	4.45	459	1.62	0.44
A_{High}B_{Low}C_{Low}	18.6	0.19	2.05	0.11	6.99	1.66	3.11	485	1.94	0.44
A_{High}B_{Low}C_{High}	19.7	0.30	2.41	0.13	3.93	1.68	2.99	477	1.31	0.91

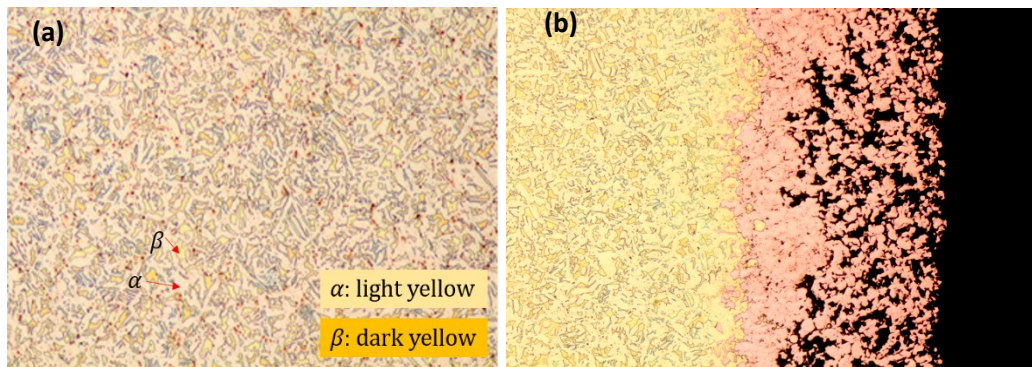


Fig. S1 The OM images of brass water meters for (a) the metallographic structure and (b) the dezincification depth.

Testing Groups	Days							
	18	32	66	104	192	250	299	376
$A_{Low}B_{Low}C_{Low}$								
$A_{High}B_{High}C_{Low}$								
$A_{High}B_{High}C_{High}$								
$A_{High}B_{Low}C_{Low}$								
$A_{High}B_{Low}C_{High}$								

Fig. S2 Scale formation on the brass water meters in the water under various mixed parameters during the 376-day experiment.

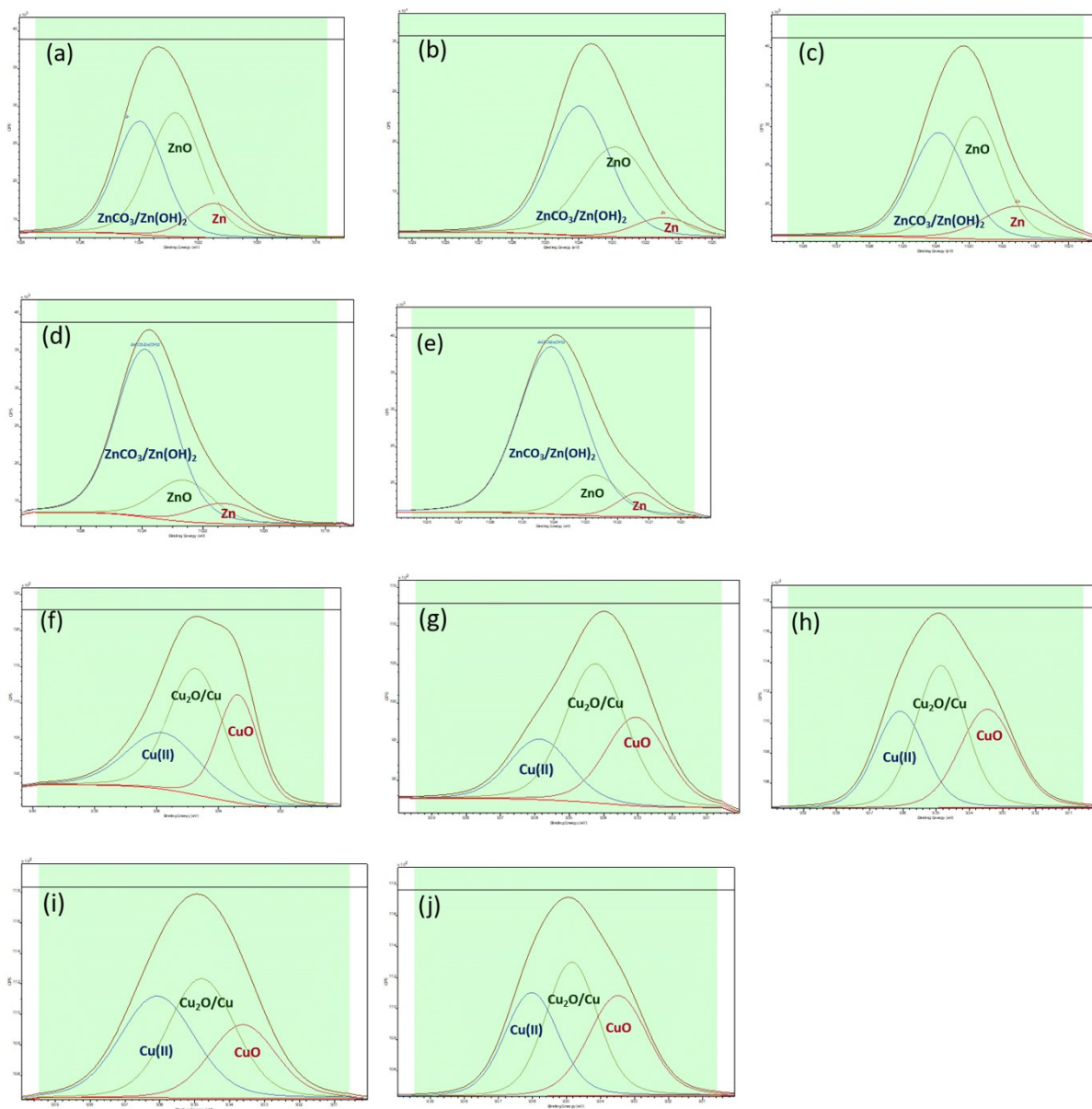


Fig. S3 The XPS core-level spectra of (a-e) Zn 2p_{3/2} and (f-j) Cu 2p_{3/2} in the scale formed from water under various mixed parameters (a and f): $A_{\text{Low}}B_{\text{Low}}C_{\text{Low}}$, (b and g): $A_{\text{High}}B_{\text{High}}C_{\text{Low}}$, (c and h): $A_{\text{High}}B_{\text{High}}C_{\text{High}}$, (d and i): $A_{\text{High}}B_{\text{Low}}C_{\text{Low}}$, (e and j): $A_{\text{High}}B_{\text{Low}}C_{\text{High}}$

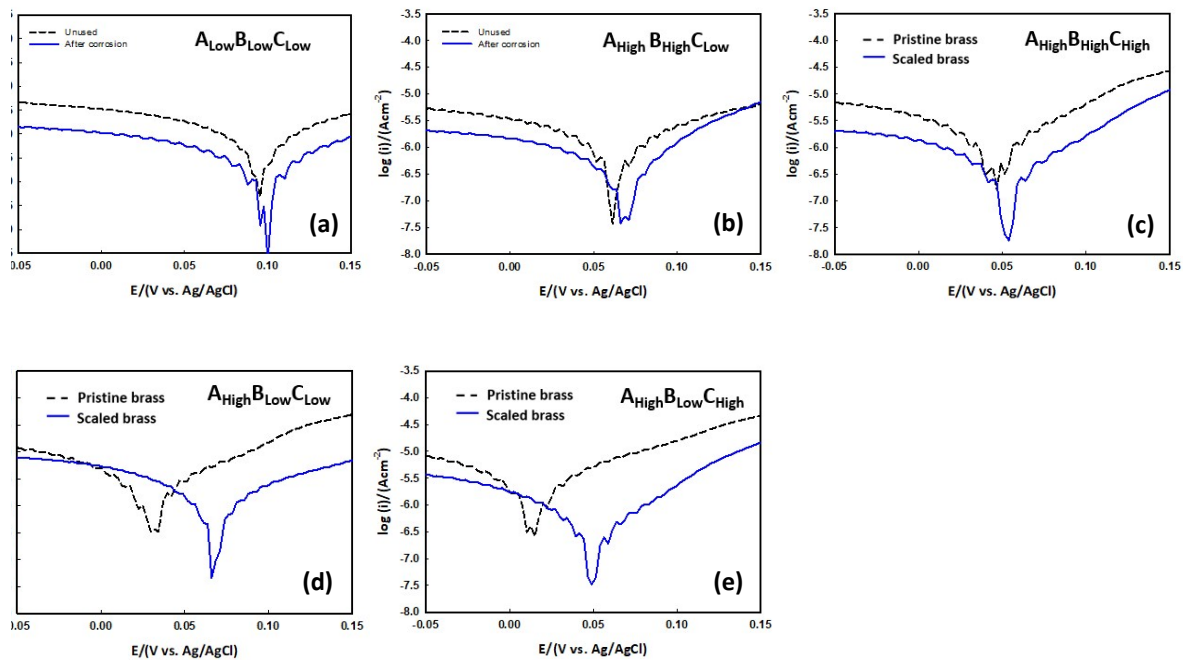


Fig. S4 The positive shift in E_{corr} of the pristine and scaled brass chips in the water under various mixed parameters: (a) $A_{\text{Low}}B_{\text{Low}}C_{\text{Low}}$ (b) $A_{\text{High}}B_{\text{High}}C_{\text{Low}}$ (c) $A_{\text{High}}B_{\text{High}}C_{\text{High}}$ (d) $A_{\text{High}}B_{\text{Low}}C_{\text{Low}}$ (e) $A_{\text{High}}B_{\text{Low}}C_{\text{High}}$.